

In the Specification:

Please amend the second full paragraph on Page 6 (particularly lines 15-16) as follows:

In another aspect of the present invention, a method of forming a barrier rib of PDP includes the steps of forming a white paste layer on a glass substrate and forming a photosensitive black resist layer on the white paste layer, forming a photosensitive black resist pattern by patterning the photosensitive black resist layer, heating the photosensitive black resist pattern so that a wax component contained in the photosensitive black resist pattern diffuses inside the photosensitive black resist pattern, and removing a portion of the white paste layer failing to be covered with the photosensitive black resist pattern and plasticizing the photosensitive black resist pattern and ~~the remaining photosensitive black resist pattern~~ the remaining white paste layer.